

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	44	(((((integrated near circuit) and (metal near layer)) and (silicon near wafer)) and (dielectric near layer) and (barrier near layer near (silicon near (nitride oxynitride carbide))))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L2	24	L1 and (dual near damascene)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L3	19	((\$silsesquioxane) same ((radiation photosensitive light ultraviolet UV!) near (curable cured curing crosslinked crosslinking crosslink polymerizing polymerizable))) and (silica silicate silicalite)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L4	28	((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and (silicate silicalite)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L5	42	((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and binder	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L6	33	(silicalite and dielectric) and binder	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L7	79	((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and dielectric	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L8	16	((((binder) same (radiation photosensitive light ultraviolet))) same \$silsesquioxane	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L9	19	((\$silsesquioxane) same ((radiation photosensitive light ultraviolet UV!) near (curable cured curing crosslinked crosslinking crosslink polymerizing polymerizable))) and (silica silicate silicalite)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45

L10	119	((porous same (silica silicate silicalite)) same (((binder) same (radiation photosensitive light ultraviolet)))) not (((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and (silicate silicalite)) (((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and binder) ((silicalite and dielectric) and binder) (((POSS (polyderal near oligomeric near silsesquioxane)) same (radiation photosensitive light methacrylate (meth near acrylate) ultraviolet)) and dielectric) (((binder) same (radiation photosensitive light ultraviolet)) and dielectric) and inhomogeneous) (((binder) same (radiation photosensitive light ultraviolet))) same \$silsesquioxane) (((\$silsesquioxane) same ((radiation photosensitive light ultraviolet UV!) near (curable cured curing crosslinked crosslinking crosslink polymerizing polymerizable))) and (silica silicate silicalite)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L11	38	(porous same (silica silicate silicalite)) same (((binder) same (radiation photosensitive ultraviolet)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L12	4	(integrated near circuit) and ((porous same (silica silicate silicalite)) and (((binder) same (radiation photosensitive ultraviolet))))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L13	86	(porous near (silica silicate silicalite (silicon near dioxide) "sio?sub.2")) and (((binder) same (radiation photosensitive ultraviolet)))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L14	2	(integrated near circuit) and ((porous near (silica silicate silicalite (silicon near dioxide) "sio?sub.2")) and (((binder) same (radiation photosensitive ultraviolet))))	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45

L15	7	(((integrated near circuit) and (metal near layer)) and (silicon near wafer)) and (dielectric near layer)) and 252/570;524/588;522/99, 148;528/32.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:45
L16	8123045	L3 L4 L5 L6 L7 S "37" L8 L9 L10 L11 L12 L13 L14 L15 L1 L2	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:46
L17	53	(((binder) same (radiation photosensitive light ultraviolet)) and dielectric) and inhomogeneous	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:46
L18	53	L17	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:46
L19	506	L3 L4 L5 L6 L7 L17 L8 L9 L10 L11 L12 L13 L14 L15 L1 L2	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:47
L20	46	19 and @pd>"20040618"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2004/11/12 15:47